



PATENT Docket No. 506212001200

Examiner: Fernando L. Toledo

Group Art Unit: 2823

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Michihiko YANAGISAWA et al.

Serial No.: 10/

10/671,483

Filing Date:

September 29, 2003

For:

MULTI-STEP DRY ETCHING

METHOD FOR SOI WAFER

## PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

Prior to the first examination on the merits of the elected claims, please amend this application as follows:

Amendments to the Specification begin on page 2.

Amendments to the claims begin on page 3.

Remarks begin on page 8.